

	Hits	Search Text	מע	Time stamp
L Number	nics	Search leve		1
Numer	7948	((438/624) or (438/634) or (438/637) or	USPAT;	2003/03/17
	, , , , , ,	(438/737) or (438/738) or (438/740) or	US-PGPUB;	11:05
		(438/743) or (438/744) or (438/761) or	EPO; JPO;	
		(438/763) or (438/786) or (438/787) or	DERWENT;	İ
		(438/791)).CCLS.	IBM TDB	
i _	1311	(((438/624) or (438/634) or (438/637) or	USPAT;	2003/03/17
		(438/737) or (438/738) or (438/740) or	US-PGPUB;	11:06
ļ		(438/743) or (438/744) or (438/761) or	EPO; JPO;	
		(438/763) or (438/786) or (438/787) or	DERWENT;	İ
		(438/791)).CCLS.) and (etch\$3 adj stop\$4)	IBM_TDB	2000 (00 (00
	448	((((438/624) or (438/634) or (438/637) or	USPAT;	2003/03/17
		(438/737) or (438/738) or (438/740) or	US-PGPUB;	11:07
		(438/743) or (438/744) or (438/761) or	EPO; JPO;	
		(438/763) or (438/786) or (439/787) or	DERWENT;	
		(438/791)).CCLS.) and (etch\$? adj	IBM_TDB	
ļ		stop\$4)) and (silicon adj nitride) and		
	1.03	(silicon adj dioxide) ((((438/624) or (438/634) or (438/637) or	USPAT;	2003/03/17
-	461	((((438/624) of (438/634) of (438/637) of (438/737) or (438/738) or (438/740) or	US-PGPUB;	11:08
		(438/743) or (438/744) or (438/761) or	EPO; JPO;	
		(438/763) or (438/786) or (438/787) or	DERWENT;	
		(438/791)).CCLS.) and (etch\$3 adj	IBM TDB	
		stop\$4)) and ((silicon adj nitride) or	_	
		sion or (silicon adj oxynitride)) and		
		(silicon adi dioxide)		
_	422	(((((438/624) or (438/634) or (438/637)	USPAT;	2003/03/17
		or (438/737) or (438/738) or (438/740) or	US-PGPUB;	11:09
		(438/743) or (438/744) or (438/761) or	EPO; JPO;	
		(438/763) or (438/786) or (438/787) or	DERWENT;	
		(438/791)).CCLS.) and (etch\$3 adj	IBM_TDB	
		stop\$4)) and ((silicon adj nitride) or		
		sion or (silicon adj oxynitride)) and		
		(silicon adj dioxide)) and ((contact same		
	0.55	hole) or via or interconnect\$3)	USPAT;	2003/03/17
_	266	((((((438/624) or (438/634) or (438/637) or (438/737) or (438/738) or (438/740) or	US-PGPUB;	11:10
		(438/743) or (438/744) or (438/7461) or	EPO; JPO;	11.10
		(438/763) or (438/786) or (438/787) or	DERWENT;	
		(438/763) 61 (436/760) 61 (436/767) 61 (438/791)).CCLS.) and (etch\$3 adj	IBM TDB	
		stop\$4)) and ((silicon adj nitride) or		
	1	sion or (silicon adj oxynitride)) and		
		(silicon adj dioxide)) and ((contact same		
		hole) or via or interconnect\$3)) and		
		(selective\$2 same etch\$4)		
_	175	((((((438/624) or (438/634) or (438/637)	USPAT;	2003/03/17
		or (438/737) or (438/738) or (438/740) or	US-PGPUB;	11:10
		(438/743) or (438/744) or (438/761) or	EPO; JPO;	
	1	(438/763) or (438/786) or (438/787) or	DERWENT;	
		(438/791)).CCLS.) and (etch\$3 adj	IBM_TDB	
		stop\$4)) and ((silicon adj nitride) or		
		sion or (silicon adj oxynitride)) and		
		(silicon adj dioxide)) and ((contact same		
		hole) or via or interconnect\$3)) and (selective\$2 same etch\$4 same stop\$4)		
		(pereceiveds same econda same acobda)		